

# Electrodeposition of a Microconnector Bump with Deforming Geometry in 3D

This model simulates the shape evolution of a microconnector bump over time as copper deposits on an electrode surface. Transport of cupric ions in the electrolyte occurs by convection and diffusion. The electrode kinetics are described by a concentration dependent Butler-Volmer expression.

The model is an extension to 3D of the Electrodeposition of a Microconnector Bump in 2D example.

## Model Definition

The basics of the electrochemical cell, geometry and model problem are described in Electrodeposition of a Microconnector Bump in 2D. For this 3D model the Péclet number of the cell is 41.6.

Figure 1 shows the 3D model geometry. Due to symmetry the unit cell has been cut in half along the x-axis.

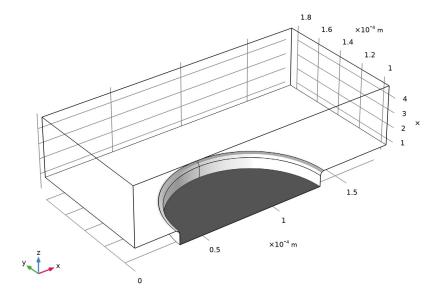


Figure 1: Model geometry. The electrolyte, flows from left to right in the x direction, over the circular hole in the photoresist mask, and exits on the right. The cathode (gray) is placed at the bottom of the circular hole. The top boundary is in contact with the electrolyte bulk.

In the 2D model, the cupric ion concentration is set to zero on the electrode surface, and the electrode current density is calculated from the electrolyte flux variable. In this 3D model however, in order to improve the stability of the deforming boundary, a concentration dependent Butler-Volmer expression is used to describe the current density at the cathode.

On the bottom boundary, the cathode, the electrode reaction

$$Cu^{2+}(1) + 2e^{-} = Cu(s)$$

follows the following kinetics expression for the charge transfer current  $i_{ct}$ :

$$i_{\rm ct} = i_0 \!\! \left( \exp \! \left( \frac{1.5 F \eta}{RT} \right) - \frac{c_{\rm Cu^{2+}}}{c_{\rm Cu^{2+}, ref}} \! \exp \! \left( - \frac{0.5 F \eta}{RT} \right) \right) \label{eq:ict}$$

where  $i_0$  is the exchange current density (10 A/m<sup>2</sup>),  $\eta$  the overpotential, F Faraday's constant (96,485 C/mol), R the molar gas constant (8.13 J/(mol·K)), T the temperature,  $c_{\mathrm{Cu^{2+}}}$  the electrolyte cupric ion concentration (mol/m³), and  $c_{\mathrm{Cu^{2+},ref}}$ , the reference cupric concentration in the bulk electrolyte (600 mol/m³).

The electrode reaction causes the electrode boundary to move in the normal direction with a velocity  $v_{\text{dep}}$  (m/s) according to

$$v_{\text{dep}} = -\frac{M_{\text{Cu}}i_{\text{ct}}}{\rho_{\text{Cu}}2F}$$

where  $M_{\text{Cu}}$  is the molar mass (0.06355 kg/mol) and  $\rho_{\text{Cu}}$  the density (8,960 kg/m<sup>3</sup>) of copper, respectively.

The electrode potential is set to -0.45 V. The electrolyte conductivity is set to 1 S/m, and the top bulk electrolyte boundary potential is set 0 V. All boundaries except the cathode and the top bulk electrolyte boundary are isolated.

The problem is solved in a time-dependent simulation to simulate the electrode deformation during 120 s.

#### Results and Discussion

Figure 2 shows the concentration in the cell at t = 0 s. The concentration along the zxplane is qualitatively similar to Figure 5 of the 2D model, with the main differences being the cupric concentration at the electrode surface. This difference is due to the changed

boundary condition, with a limiting current condition in the 2D model and a mixed concentration/activation condition in the 3D model.

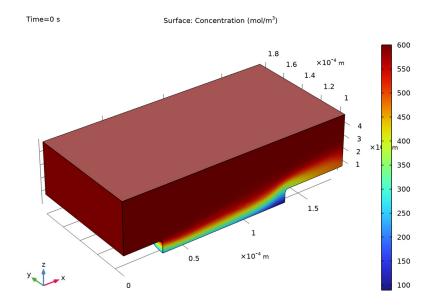


Figure 2:  $Cu^{2+}$  concentration in the cell at t = 0.

Figure 3 shows the concentration at t = 120 s. The minimum concentration is now higher compared to t = 0 s due to a shorter transport length of ions toward the electrode surface.

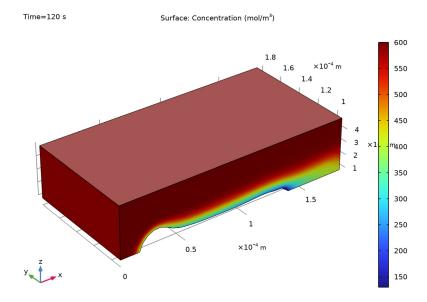


Figure 3:  $Cu^{2+}$  concentration in the cell at t = 120.

Figure 4 shows the electrode surface at t = 120 s. The deposit is thicker toward the left in the figure, and the shape follows the same trend as was seen in Figure 7 of the 2D model.

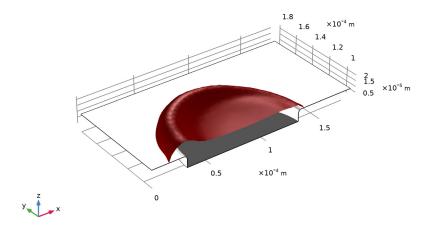


Figure 4: Microconnector bump surface (red) at t = 120 s.

# Notes About the COMSOL Implementation

The model is solved using two stationary steps followed by a time-dependent step. The first stationary step solves for the laminar flow only. The second stationary step solves for the concentration and initial current distribution in the cell. The results from the two initial steps are used as initial values for the third time-dependent study step.

# Reference

K. Kondo, K. Fukui, K. Uno, and K. Shonohara, "Shape Evolution of Electrodeposited Copper Bumps," J. Electrochemical Society, vol. 143, pp 1880–1886, 1996.

**Application Library path:** Electrodeposition\_Module/Tutorials/ microconnector\_bump\_3d

From the File menu, choose New.

#### NEW

In the New window, click Model Wizard.

#### MODEL WIZARD

- I In the Model Wizard window, click 📋 3D.
- 2 In the Select Physics tree, select Electrochemistry>Electrodeposition, Deformed Geometry> Electrodeposition, Tertiary with Supporting Electrolyte.
- 3 Click Add.
- 4 In the Number of species text field, type 1.
- 5 In the Concentrations (mol/m³) table, enter the following settings:

С

- 6 In the Select Physics tree, select Fluid Flow>Single-Phase Flow>Laminar Flow (spf).
- 7 Click Add.
- 8 Click **Done**.

#### GLOBAL DEFINITIONS

Load the model parameters from a text file.

#### Parameters 1

- I In the Model Builder window, under Global Definitions click Parameters I.
- 2 In the Settings window for Parameters, locate the Parameters section.
- 3 Click Load from File.
- **4** Browse to the model's Application Libraries folder and double-click the file microconnector\_bump\_parameters.txt.

#### DEFINITIONS

Load also some variables from a text file.

## Variables 1

- I In the Model Builder window, under Component I (compl) right-click Definitions and choose Variables.
- 2 In the Settings window for Variables, locate the Variables section.
- 3 Click Load from File.
- **4** Browse to the model's Application Libraries folder and double-click the file microconnector\_bump\_3d\_variables.txt.

#### **GEOMETRY I**

Draw the geometry as a block and a cylinder (for the hole in the photoresist film). Round off the sharp corners of the film by using an additional cylinder and a torus. Finally, use the symmetry of the problem by cutting the model geometry in half.

## Block I (blk I)

- I In the Geometry toolbar, click Block.
- 2 In the Settings window for Block, locate the Size and Shape section.
- 3 In the Width text field, type Ltot.
- 4 In the **Depth** text field, type Ltot.
- **5** In the **Height** text field, type h2.
- 6 Locate the Position section. In the z text field, type h1.

## Cylinder I (cyl1)

- I In the Geometry toolbar, click ( Cylinder.
- 2 In the Settings window for Cylinder, locate the Size and Shape section.
- 3 In the Radius text field, type L1/2.
- 4 In the Height text field, type h1.
- 5 Locate the Position section. In the x text field, type L3+L1/2.
- 6 In the y text field, type Ltot/2.
- 7 Click | Build Selected.
- **8** Click the Transparency button in the Graphics toolbar.
- 9 Right-click Cylinder I (cyll) and choose Duplicate.

#### Cylinder 2 (cyl2)

- I In the Model Builder window, click Cylinder 2 (cyl2).
- 2 In the Settings window for Cylinder, locate the Size and Shape section.
- 3 In the Radius text field, type L1/2+r edge.
- 4 In the **Height** text field, type r edge.
- 5 Locate the **Position** section. In the z text field, type h1-r edge.
- 6 Click | Build Selected.

#### Torus I (torl)

- I In the Geometry toolbar, click O Torus.
- 2 In the Settings window for Torus, locate the Size and Shape section.
- 3 In the Major radius text field, type L1/2+r edge.

- 4 In the Minor radius text field, type r\_edge.
- 5 Locate the Position section. In the x text field, type L3+L1/2.
- 6 In the y text field, type Ltot/2.
- 7 In the z text field, type h1-r\_edge.
- 8 Click Pauld Selected.

Difference I (dif1)

- I In the Geometry toolbar, click Booleans and Partitions and choose Difference.
- 2 Select the object cyl2 only.
- 3 In the Settings window for Difference, locate the Difference section.
- 4 Click to select the **Activate Selection** toggle button for **Objects to subtract**.
- **5** Select the object **torl** only.
- 6 Click Pauld Selected.

Union I (uni I)

- I In the Geometry toolbar, click Booleans and Partitions and choose Union.
- 2 Click in the **Graphics** window and then press Ctrl+A to select all objects.
- 3 In the Settings window for Union, locate the Union section.
- 4 Clear the Keep interior boundaries check box.
- 5 Click Pauld Selected.

Work Plane I (wpl)

- I In the Geometry toolbar, click Work Plane.
- 2 In the Settings window for Work Plane, locate the Plane Definition section.
- 3 From the Plane list, choose xz-plane.
- 4 In the y-coordinate text field, type Ltot/2.

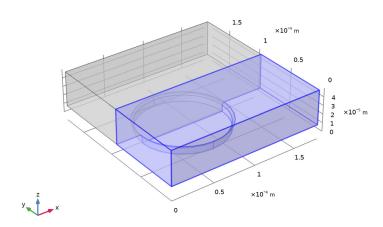
Partition Objects I (par I)

- I In the Geometry toolbar, click Booleans and Partitions and choose Partition Objects.
- **2** Select the object **unil** only.
- 3 In the Settings window for Partition Objects, locate the Partition Objects section.
- 4 From the Partition with list, choose Work plane.
- 5 Click **Build Selected**.

Delete Entities I (del1)

I In the Model Builder window, right-click Geometry I and choose Delete Entities.

- 2 In the Settings window for Delete Entities, locate the Entities or Objects to Delete section.
- 3 From the Geometric entity level list, choose Domain.
- 4 On the object parl, select Domain 1 only.



- 5 Click Pauld Selected.
- 6 Click the **Zoom Extents** button in the **Graphics** toolbar.

#### DEFINITIONS

Add a number of selections to facilitate choosing various parts of the geometry when setting up the physics later.

#### Inlet

- I In the **Definitions** toolbar, click **\( \frac{1}{2} \) Explicit**.
- 2 In the Settings window for Explicit, locate the Input Entities section.
- 3 From the Geometric entity level list, choose Boundary.
- 4 Select Boundary 1 only.
- 5 In the Label text field, type Inlet.

## Outlet

- I In the **Definitions** toolbar, click **\( \bigcap\_{\bigcap} \) Explicit**.
- 2 In the Settings window for Explicit, locate the Input Entities section.
- 3 From the Geometric entity level list, choose Boundary.

- 4 Select Boundary 11 only.
- 5 In the Label text field, type Outlet.

## Symmetry Walls

- I In the **Definitions** toolbar, click **\( \bigcap\_{\text{a}} \) Explicit**.
- 2 In the Settings window for Explicit, locate the Input Entities section.
- 3 From the Geometric entity level list, choose Boundary.
- 4 Select Boundaries 2 and 5 only.
- 5 In the Label text field, type Symmetry Walls.

## Cathode

- I In the **Definitions** toolbar, click **\( \frac{1}{2} \) Explicit**.
- 2 In the Settings window for Explicit, locate the Input Entities section.
- 3 From the Geometric entity level list, choose Boundary.
- **4** Select Boundary 8 only.
- 5 In the Label text field, type Cathode.

## Bulk Electrolyte

- I In the **Definitions** toolbar, click **\( \bigcap\_{\text{a}} \) Explicit**.
- 2 In the Settings window for Explicit, locate the Input Entities section.
- 3 From the Geometric entity level list, choose Boundary.
- **4** Select Boundary 4 only.
- 5 In the Label text field, type Bulk Electrolyte.

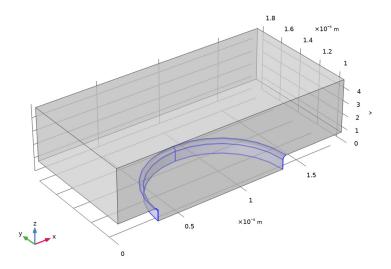
## Inlet + Bulk Electrolyte

- I In the **Definitions** toolbar, click **Union**.
- 2 In the Settings window for Union, locate the Geometric Entity Level section.
- 3 From the Level list, choose Boundary.
- **4** Locate the **Input Entities** section. Under **Selections to add**, click + **Add**.
- 5 In the Add dialog box, in the Selections to add list, choose Inlet and Bulk Electrolyte.
- 6 Click OK.
- 7 In the Settings window for Union, type Inlet + Bulk Electrolyte in the Label text field.

#### Insulator Hole Walls

I In the **Definitions** toolbar, click **\( \frac{1}{3} \) Explicit**.

- 2 In the Settings window for Explicit, locate the Input Entities section.
- 3 From the Geometric entity level list, choose Boundary.
- **4** Select Boundaries 6, 7, 9, and 10 only.



5 In the Label text field, type Insulator Hole Walls.

## TERTIARY CURRENT DISTRIBUTION, NERNST-PLANCK (TCD)

Set up the current distribution and deforming geometry in the Electrodeposition, Tertiary with Supporting Electrolyte interface.

## Electrolyte I

Now set up the convection and diffusion part of the problem using Tertiary Current Distribution Nernst-Planck.

- I In the Model Builder window, under Component I (compl)>Tertiary Current Distribution, Nernst-Planck (tcd) click Electrolyte I.
- 2 In the Settings window for Electrolyte, locate the Convection section.
- 3 From the u list, choose Velocity field (spf).
- **4** Locate the **Diffusion** section. In the  $D_{\mathrm{c}}$  text field, type D.
- **5** Locate the **Solvent** section. From the  $\sigma_1$  list, choose **User defined**. In the associated text field, type 1.

#### Initial Values 1

- I In the Model Builder window, click Initial Values I.
- 2 In the Settings window for Initial Values, locate the Initial Values section.
- **3** In the *c* text field, type c\_bulk.

#### Concentration - Bulk

- I In the Physics toolbar, click **Boundaries** and choose Concentration.
- 2 In the Settings window for Concentration, type Concentration Bulk in the Label text field.
- 3 Locate the Boundary Selection section. From the Selection list, choose Inlet + Bulk Electrolyte.
- **4** Locate the **Concentration** section. Select the **Species c** check box.
- **5** In the  $c_{0,c}$  text field, type c\_bulk.

## Electrolyte Potential - Bulk

- I In the Physics toolbar, click **Boundaries** and choose **Electrolyte Potential**.
- 2 In the Settings window for Electrolyte Potential, type Electrolyte Potential Bulk in the Label text field.
- 3 Locate the Boundary Selection section. From the Selection list, choose Bulk Electrolyte.

#### Electrode Surface 1

- I In the Physics toolbar, click **Boundaries** and choose **Electrode Surface**.
- 2 In the Settings window for Electrode Surface, click to expand the Dissolving-Depositing Species section.
- 3 Click + Add.
- 4 Clear the Solve for surface concentration variables check box.
- 5 Locate the Boundary Selection section. From the Selection list, choose Cathode.
- **6** Locate the **Electrode Phase Potential Condition** section. In the  $\phi_{s,ext}$  text field, type 0.45.

#### Electrode Reaction I

Now define the concentration-dependent kinetics for cupric ions on the cathode.

- I In the Model Builder window, click Electrode Reaction I.
- 2 In the Settings window for Electrode Reaction, locate the Stoichiometric Coefficients section.
- 3 In the n text field, type 2.

- 4 In the  $v_c$  text field, type -1.
- 5 In the Stoichiometric coefficients for dissolving-depositing species: table, enter the following settings:

Species	Stoichiometric coefficient (I)
sl	1

**6** Click to expand the **Reference Concentrations** section. In the table, enter the following settings:

Electrolyte species	Reference concentrations (mol/m^3)
с	c_bulk

- 7 Locate the **Electrode Kinetics** section. In the  $i_{0,ref}(T)$  text field, type 10[A/m^2].
- **8** In the  $\alpha_a$  text field, type 1.5.

## Outflow I

- I In the Physics toolbar, click **Boundaries** and choose **Outflow**.
- 2 In the Settings window for Outflow, locate the Boundary Selection section.
- 3 From the Selection list, choose Outlet.
  - Linear shape functions for concentration, electrolyte potential and electric potential are sufficient for this model setup. They also result in reduced computation time and memory requirements when compared to the default quadratic shape functions.
- 4 In the Model Builder window, click Tertiary Current Distribution, Nernst-Planck (tcd).
- 5 In the Settings window for Tertiary Current Distribution, Nernst-Planck, click to expand the **Discretization** section.
- 6 From the Concentration list, choose Linear.
- 7 From the Electrolyte potential list, choose Linear.
- 8 From the Electric potential list, choose Linear.

## LAMINAR FLOW (SPF)

Set up the flow.

## Fluid Properties 1

- I In the Model Builder window, under Component I (compl)>Laminar Flow (spf) click Fluid Properties 1.
- 2 In the Settings window for Fluid Properties, locate the Fluid Properties section.
- **3** From the  $\rho$  list, choose **User defined**. In the associated text field, type rho.

**4** From the  $\mu$  list, choose **User defined**. In the associated text field, type mu.

## Symmetry I

- I In the Physics toolbar, click **Boundaries** and choose Symmetry.
- 2 In the Settings window for Symmetry, locate the Boundary Selection section.
- 3 From the Selection list, choose Symmetry Walls.

#### Inlet I

- I In the Physics toolbar, click **Boundaries** and choose **Inlet**.
- 2 In the Settings window for Inlet, locate the Boundary Selection section.
- **3** From the **Selection** list, choose **Inlet**.
- **4** Locate the **Velocity** section. Click the **Velocity** field button.
- **5** Specify the  $\mathbf{u}_0$  vector as

u_profile	x
0	у
0	z

#### Wall 2

- I In the Physics toolbar, click **Boundaries** and choose Wall.
- 2 In the Settings window for Wall, locate the Boundary Selection section.
- 3 From the Selection list, choose Bulk Electrolyte.
- 4 Click to expand the Wall Movement section. From the Translational velocity list, choose Manual.
- **5** Specify the  $\mathbf{u}_{tr}$  vector as

u_bulk	x
0	у
0	z

#### Outlet I

- I In the Physics toolbar, click **Boundaries** and choose **Outlet**.
- 2 In the Settings window for Outlet, locate the Boundary Selection section.
- **3** From the **Selection** list, choose **Outlet**.

#### MULTIPHYSICS

Nondeforming Boundary 2 (ndbdg2)

- I In the Physics toolbar, click Multiphysics Couplings and choose Boundary> Nondeforming Boundary.
- 2 Select Boundaries 1, 2, 4, 5, and 11 only.
- 3 In the Settings window for Nondeforming Boundary, locate the Nondeforming Boundary section.
- 4 From the Boundary condition list, choose Zero normal displacement.

#### MESH I

Size 1

- I In the Model Builder window, under Component I (compl) right-click Mesh I and choose Size.
- 2 In the Settings window for Size, locate the Geometric Entity Selection section.
- 3 From the Geometric entity level list, choose Boundary.
- 4 From the Selection list, choose Insulator Hole Walls.
- **5** Locate the **Element Size** section. Click the **Custom** button.
- 6 Locate the Element Size Parameters section.
- 7 Select the Maximum element size check box. In the associated text field, type 3E-6.

Size

- I In the Model Builder window, click Size.
- 2 In the Settings window for Size, click to expand the Element Size Parameters section.
- 3 In the Maximum element size text field, type 8E-6.
- 4 In the Maximum element growth rate text field, type 1.1.
- 5 In the Curvature factor text field, type 0.7.

## Mapped I

- I In the Mesh toolbar, click \times More Generators and choose Mapped.
- 2 In the Settings window for Mapped, locate the Boundary Selection section.
- 3 From the Selection list, choose Insulator Hole Walls.
- 4 Click to expand the Advanced Settings section. From the Interpolation method list, choose Transfinite in 3D.

## Convert I

- I In the Mesh toolbar, click **Modify** and choose Convert.
- 2 In the Settings window for Convert, locate the Geometric Entity Selection section.
- 3 From the Geometric entity level list, choose Boundary.
- 4 From the Selection list, choose Insulator Hole Walls.
- 5 Click Build Selected.

## Free Tetrahedral I

- I In the Mesh toolbar, click A Free Tetrahedral.
- 2 In the Settings window for Free Tetrahedral, click | Build Selected.

## Boundary Layers 1

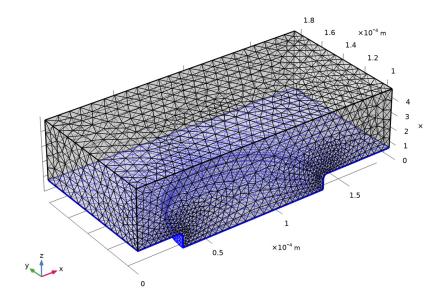
- I In the Mesh toolbar, click Boundary Layers.
- 2 In the Settings window for Boundary Layers, click to expand the Corner Settings section.
- 3 From the Handling of sharp edges list, choose Trimming.
- 4 Click to expand the Transition section. Clear the Smooth transition to interior mesh check box.

## Boundary Layer Properties

- I In the Model Builder window, click Boundary Layer Properties.
- **2** Select Boundaries 3 and 6–10 only.
- 3 In the Settings window for Boundary Layer Properties, locate the Layers section.
- 4 In the Number of layers text field, type 1.
- 5 From the Thickness specification list, choose First layer.
- 6 In the Thickness text field, type 0.5E-6.
- 7 Click III Build All.

Your finished mesh should now look like this:

## 8 Right-click Boundary Layer Properties and choose Plot.



#### ROOT

Solve the problem using three different steps. The first study step solves for the flow profile at t = 0.

## ADD STUDY

- I In the Home toolbar, click Add Study to open the Add Study window.
- **2** Go to the **Add Study** window.
- 3 Find the Studies subsection. In the Select Study tree, select General Studies>Stationary.
- 4 Click Add Study in the window toolbar.
- 5 In the Home toolbar, click Add Study to close the Add Study window.

## STUDY I

## Step 1: Stationary

- I In the Settings window for Stationary, locate the Physics and Variables Selection section.
- 2 Select the Modify model configuration for study step check box.
- 3 In the tree, select Component I (compl)>Tertiary Current Distribution, Nernst-Planck (tcd).

- 4 Click O Disable in Solvers.
- 5 In the tree, select Component I (compl)>Multiphysics> Nondeforming Boundary I (ndbdgl), Component I (compl)>Multiphysics> Deforming Electrode Surface I (desdgl), and Component I (compl)>Multiphysics> Nondeforming Boundary 2 (ndbdg2).
- 6 Click O Disable in Solvers.

## Step 2: Stationary 2

Add a second step to solve for the concentration and current distribution at t = 0.

- I In the Study toolbar, click study Steps and choose Stationary>Stationary.
- 2 In the Settings window for Stationary, locate the Physics and Variables Selection section.
- 3 Select the Modify model configuration for study step check box.
- 4 In the tree, select Component I (compl)>Laminar Flow (spf).
- 5 Right-click and choose Disable in Solvers.
- 6 In the tree, select Component I (compl)>Multiphysics> Nondeforming Boundary I (ndbdgl), Component I (compl)>Multiphysics> Deforming Electrode Surface I (desdgl), and Component I (compl)>Multiphysics> Nondeforming Boundary 2 (ndbdg2).
- 7 Right-click and choose Disable in Solvers.

#### Steb 3: Time Debendent

Add a third and final time dependent step to solve for the problem during 120 s. The results from the first two steps will be used as initial values automatically.

- I In the Study toolbar, click Study Steps and choose Time Dependent>
- 2 In the Settings window for Time Dependent, locate the Study Settings section.
- 3 In the Output times text field, type range (0, 10, 120).

Solution I (soll)

- I In the Study toolbar, click Show Default Solver.
- 2 In the Model Builder window, expand the Solution I (soll) node.
- 3 In the Model Builder window, expand the Study I>Solver Configurations> Solution I (solI)>Time-Dependent Solver I node, then click Segregated I.
- 4 In the Settings window for Segregated, locate the General section.
- 5 In the Maximum number of iterations text field, type 15.

- 6 In the Model Builder window, expand the Study I>Solver Configurations> Solution I (soll)>Time-Dependent Solver I>Segregated I node, then click Velocity u, Pressure p.
- 7 In the Settings window for Segregated Step, click to expand the Method and Termination section.
- 8 From the Jacobian update list, choose On first iteration.
- 9 In the Model Builder window, under Study I>Solver Configurations>Solution I (soll)> Time-Dependent Solver I>Segregated I click Merged Variables.
- 10 In the Settings window for Segregated Step, locate the Method and Termination section.
- II From the Termination technique list, choose Tolerance.
- 12 In the Model Builder window, click Study 1.
- 13 In the Settings window for Study, locate the Study Settings section.
- **14** Clear the **Generate default plots** check box.
- **15** In the **Study** toolbar, click **Compute**.

#### RESULTS

#### Concentration

- I In the Home toolbar, click Add Plot Group and choose 3D Plot Group.
- 2 In the Settings window for 3D Plot Group, type Concentration in the Label text field.

#### Surface 1

- I Right-click Concentration and choose Surface.
- 2 In the Settings window for Surface, locate the Expression section.
- **3** In the **Expression** text field, type **c**.
- 4 In the Concentration toolbar, click Plot.
- 5 Click the Transparency button in the Graphics toolbar.

#### Concentration

- I In the Model Builder window, click Concentration.
- 2 In the Settings window for 3D Plot Group, locate the Data section.
- 3 From the Time (s) list, choose 0.
- 4 In the Concentration toolbar, click  **Plot**.
- **5** Right-click **Concentration** and choose **Duplicate**.

## Microconnector Bump Surface

- I In the Model Builder window, expand the Results>Concentration I node, then click Concentration I.
- 2 In the Settings window for 3D Plot Group, type Microconnector Bump Surface in the Label text field.
- 3 Locate the Data section. From the Time (s) list, choose 120.
- 4 Click to expand the **Title** section. From the **Title type** list, choose **None**.
- 5 Locate the Plot Settings section. Clear the Plot dataset edges check box.

#### Surface I

- I In the Model Builder window, click Surface I.
- 2 In the Settings window for Surface, locate the Expression section.
- **3** In the **Expression** text field, type 1.
- 4 Locate the Coloring and Style section. From the Coloring list, choose Uniform.
- **5** From the **Color** list, choose **Custom**.
- **6** On Windows, click the colored bar underneath, or if you are running the crossplatform desktop the **Color** button.
- 7 Click Define custom colors.
- **8** Set the RGB values to 128, 0, and 0, respectively.
- 9 Click Add to custom colors.
- 10 Click Show color palette only or OK on the cross-platform desktop.
- II Click to expand the Quality section. From the Resolution list, choose Fine.

#### Selection 1

- I Right-click Surface I and choose Selection.
- 2 Select Boundary 8 only.

#### Surface 2

- I In the Model Builder window, right-click Microconnector Bump Surface and choose Surface.
- 2 In the Settings window for Surface, locate the Data section.
- 3 From the Dataset list, choose Study I/Solution Store I (sol2).
- **4** Locate the **Expression** section. In the **Expression** text field, type 1.
- 5 Locate the Coloring and Style section. From the Coloring list, choose Uniform.
- 6 From the Color list, choose White.

7 Locate the Quality section. From the Resolution list, choose Fine.

#### Selection I

- I Right-click Surface 2 and choose Selection.
- 2 In the Settings window for Selection, locate the Selection section.
- 3 Click Paste Selection.
- 4 In the Paste Selection dialog box, type 3, 6-7, 9-10 in the Selection text field.
- 5 Click OK.

#### RESULTS

#### Surface 2

- I In the Model Builder window, collapse the Results>Microconnector Bump Surface> Surface 2 node.
- 2 Right-click Surface 2 and choose Duplicate.

#### Surface 3

- I In the Model Builder window, expand the Results>Microconnector Bump Surface> Surface 3 node, then click Surface 3.
- 2 In the Settings window for Surface, locate the Coloring and Style section.
- 3 From the Color list, choose Black.

## Selection I

- I In the Model Builder window, click Selection I.
- 2 In the Settings window for Selection, locate the Selection section.
- 3 Click Clear Selection.
- 4 Click Paste Selection.
- 5 In the Paste Selection dialog box, type 8 in the Selection text field.
- 6 Click OK.

#### line l

- I In the Model Builder window, right-click Microconnector Bump Surface and choose Line.
- 2 In the Settings window for Line, locate the Data section.
- 3 From the Dataset list, choose Study I/Solution Store I (sol2).
- **4** Locate the **Expression** section. In the **Expression** text field, type 1.
- 5 Locate the Coloring and Style section. From the Coloring list, choose Uniform.
- **6** From the **Color** list, choose **Black**.

## Selection I

- I Right-click Line I and choose Selection.
- 2 In the Settings window for Selection, locate the Selection section.
- 3 Click Paste Selection.
- 4 In the Paste Selection dialog box, type 2-3, 7, 9, 11-13, 16, 20-22, 24 in the Selection text field.
- 5 Click OK.

#### Animation I

- I In the Results toolbar, click Animation and choose Player.
- 2 In the Settings window for Animation, locate the Scene section.
- 3 From the Subject list, choose Microconnector Bump Surface.
- 4 Locate the Frames section. In the Number of frames text field, type 13.
- 5 In the Frame number text field, type 13.
- **6** Click the Play button in the Graphics toolbar.